The 8th International Conference on Microelectronics and Plasma Technology | The 9th International Symposium on Functional Materials

## Joint International Conference on The 8th ICMAP & The 9th ISFM

January 17-20, 2021 | Online Conference

[WC4] Plasma Process for Environmental Issues	
Date / Time	January 20 (Wed.), 2021 / 15:20-17:00
Place	Channel C
Session Chair(s)	Oi Lun Li (Pusan Nat'l Univ., Korea)

[WC4-1] Invited 15:20-15:50

Plasma-Modified Catalysts and Catalysis: Application to Greenhouse Gas Utilization

Tomohiro Nozaki, Zunrong Sheng, and Xiaozhong Chen *Tokyo Inst. of Tech., Japan* 

[WC4-2] 15:50-16:10

Effect of Humidity on ZnO Nanowire Structures Synthesized by Atmospheric Pressure Microwave Plasma System

Byeong-Joo Lee, Sung-II Jo, Woo-Young Lee, Seong-Gyu Heo, and Goo-Hwan Jeong Kangwon Nat'l Univ., Korea

[WC4-3] Invited 16:10-16:40

Plasma-Catalytic Conversion of Air Pollutants: Investigation of Reaction Process and Synergy Mechanism

Daiqi Ye, Junliang Wu, Peirong Chen, Haomin Chen, Limin Chen, and Mingli Fu South China Univ. of Tech., China

[WC4-4] 16:40-17:00

Digital Twin Development of a CCP Dry Etcher for 300 mm Wafers

Junghoon Joo<sup>1</sup>, Hyoungcheol Kwon<sup>2</sup>, Jong-Won Park<sup>2</sup>, and Sung Kye Park<sup>2</sup>

<sup>1</sup>Kunsan Nat'l Univ., Korea, <sup>2</sup>SK hynix, Korea